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**ASSESSING THE TRIBOCORROSION BEHAVIOUR OF Cu AND Al
BY ELECTROCHEMICAL IMPEDANCE SPECTROSCOPY**

Jean Geringer^a, Bernard Normand^b, Catherine Alemany-Dumont^b, Robert Diemiaszonek^b

*^aEcole Nationale Supérieure des Mines de Saint-Etienne, Center for Health Engineering,
UMR CNRS 5146, IFR 143, Biomechanics and Biomaterials Department,
158 cours Fauriel, 42 023 Saint-Etienne Cedex 02, France
Tel: +33 477 426 688; Fax: +33 477 420 157; geringer@emse.fr*

*^bINSA-Lyon, MATEIS CNRS UMR 5510, RI₂S group, Domaine Scientifique de la Doua,
7 av. Jean Capelle, Bât. L. de Vinci, 69 621 Villeurbanne Cedex, France
Tel: +33 472 436 287; Fax: +33 472 438 528;
Bernard Normand : Bernard.normand@insa-lyon.fr
Catherine Alemany-Dumont: catherine.alemany-dumont@insa-lyon.fr
Robert Diemiaszonek: robert.diemiaszonek@insa-lyon.fr*

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Abstract

This study is focused on the interests and limits of Electrochemical Impedance Spectroscopy, to establish the electrochemical behaviour of a tribosystem between Cu and Al, in acid solution. The calculated capacitance, in high frequency range, partially allows understanding the double layer state of body in the contact. The Potential of Zero Charge was calculated for Cu sample and it was associated to a potential range for Al. PZC value of each material is discussed as a key parameter of sliding contact. During tests of wear, the EIS results are related to the evolution of adsorbed water molecules.

Keywords: Tribocorrosion; Cu; Al; EIS.

1 **1. Introduction**

2 Tribocorrosion is defined as materials degradation of solids in contact resulting from
3 chemical, electrochemical and mechanical processes. These surface interactions occur during
4 rolling and/or sliding contact between two materials in a corrosive medium such as an
5 aqueous solution [1]. Thus, in mechanical devices, decreased performance decreasing and
6 environment contamination occur. Tribocorrosion affects numerous industrial fields such as
7 nuclear industry [2], food manufacturing or medical implants [3]. The electric and electronic
8 fields are also increasingly concerned by tribocorrosion. The investigated materials, in this
9 work, are copper and aluminium that are related with these fields.

10 Since the 70s, tribocorrosion processes have been increasingly investigated. Different
11 methods (including design of new tests) are developed to understand, to predict and to model
12 the impact of the mechanical solicitation on the electrochemical properties of materials [4].
13 As a result, tribocorrosion can be analyzed using classical electrochemical techniques: open
14 circuit potential evolution according to normal load or frequency [5]; potentiostatic
15 measurements for quantitative analysis of wear [6]; current and potential monitoring under
16 open circuit conditions, i.e. electrochemical noise measurements [7]. Electrochemical
17 Impedance Spectroscopy (noted EIS) was also described by several authors as an interesting
18 tool to investigate mechanisms occurring on both material surfaces in contact [8-10].
19 Interfacial reactivity can be modelled by an association of basic electrical components such as
20 resistance, capacitance or inductance [11]. In this study EIS experiments were performed to
21 obtain these physical values.

22 A model tribosystem based on Al-Cu has been chosen for this study because it
23 highlights galvanic coupling due to the high electrochemical potential gap in the considered
24 electrolyte [12]. Cu effect on the Al corrosion resistance is widely studied in material science
25 [13,14]. Recently galvanic corrosion between Cu and Al was particularly studied by local

1 Electrochemical Impedance Spectroscopy (LEIS) [15]. In contrast, the electrochemical
2 behaviour of the Cu/Al contact under sliding has been much less considered in acidic solution
3 using EIS technique. Acid solution was used for promoting the dissolution of metal and for
4 enhancing galvanic coupling.

5 In this paper, the electrochemical behaviour of Cu and Al was studied separately to
6 characterize the Potential of Zero Charge (noted PZC). This physical characteristic informs
7 about attraction or repulsion phenomena (which play a role in the friction evolution) between
8 two surfaces in contact [6]. The static contact was investigated to estimate the galvanic
9 coupling. Finally, the electrochemical behaviour of dynamic contact, i.e. under sliding
10 conditions was characterized. In addition, SEM and EDS were used to understand the wear
11 mechanisms.

12

13 **2. Experimental**

14 ***2.1 Materials***

15 The chemical composition of Al alloy (A 2017 [16]) was measured by spark emission
16 spectroscopy on a SEO JY 50 E equipment (Table 1).

17 **[Table 1]**

18 Cu composition was measured by electrolysis and confirmed by atomic absorption
19 spectroscopy. Because minor metallic elements such as Cr, Ni, Ag, Fe are lower than 0.002 %
20 weight percent, Cu purity was established to 99.80 %.

21 ***2.2 Tribocorrosion device***

22 A wear corrosion apparatus was developed in MATEIS laboratory, for pure sliding,
23 from reciprocating displacement, in a pin/disc configuration, figure1.

24

1 **[Figure 1]**

2 Displacement amplitude of ± 8.6 mm at a frequency of 1 Hz was applied. Electrical
3 contacts, between device and samples, were eliminated by insulation of samples and elements
4 of the tribosystem.

5 Al alloy pin is presented schematically on figure 1, with an area of 0.28 cm^2 . The
6 upper part was embedded in poly (methyl methacrylate) for electrical insulation. The lower
7 part was previously covered by cataphoretic epoxy-amine base paint.

8 The paint protects the lateral surface from corrosion in an acid solution and defines the
9 size of reactive surface. The contact diameter was equal to 6 mm. In addition, to obtain a
10 planar contact, a polishing step of the pin was carried out on the friction device with grit paper
11 of grading 180 to 2500.

12 The Cu samples were discs with a diameter of 25 mm (area of 19.63 cm^2) and a
13 thickness of 1 mm machined in industrial production. A surface roughness of $R_a = 0.10 \pm$
14 $0.05 \text{ }\mu\text{m}$ was obtained after a polishing procedure including grit paper 180 to 1200 and finally
15 a paraffin solution and alumina particles to obtain mirror surface.

16 Normal load equal to 6.7 N was applied by dint of calibrated rod fixing the contact
17 diameter and the temperature was maintained to $23 \pm 2 \text{ }^\circ\text{C}$.

18 ***2.3 Electrochemical measurement***

19 Acid solution was chosen to maintain an active state of materials constituting the
20 tribosystem [12]. The electrolyte was an aerated solution of $0.5 \text{ mol.L}^{-1} \text{ Na}_2\text{SO}_4$ having a pH
21 of 1.7 obtained by a H_2SO_4 buffer.

22 Electrochemical measurements, including free corrosion potential (E_{corr}) as a function
23 of time and electrochemical impedance measurements, were carried out.

1 A mercury/mercurous sulphate (Hg/Hg₂SO₄) reference electrode, saturated with
2 K₂SO₄ solution, was used and the ionic junction was located very close to the surface of the
3 working electrode. The potential difference against the standard hydrogen electrode (SHE)
4 was measured about 0.615 V at 25°C.

5 EIS spectra were performed in the frequency range from 10 kHz to 15 mHz at 10
6 points per Hertz decade with an AC voltage amplitude of 10 mV. Data were validated by
7 Kramers-Koenig (K-K) transformation [17,18]. Cu discs and Al pins were studied separately
8 as a working electrode before EIS diagram was performed during friction. Exposed areas of
9 Cu and Al samples were 19.63 cm² and 0.20 cm² respectively. Graphite counter electrode was
10 used with a diameter of 5 mm and a length of 70 mm. Impedance experiments were
11 conducted using Princeton Applied Research (Parstat 2263) equipment. Impedance
12 monitoring was performed at Ecorr and applied potential.

13 ***2.4 Scanning Electron Microscope***

14 Cu and Al samples were observed with a Scanning Electron Microscope (SEM) JEOL
15 6400 coupled with an EDS probe. A gold skin covered the worn surfaces, after friction tests,
16 to highlight transferred particles between two materials in contact. These particles were oxide.
17 They require a gold coating to obtain the best images and to avoid charge accumulation.

18

19 **3. Results and discussion**

20 ***3.1 Data analysis***

21 Here, the selected pH is leading to a dissolution of Al and Cu. Figure 2 illustrates
22 experimental EIS response recorded for Al alloy immersed during 3 hours in acid solution.
23 Spectrum exhibits two time constants. At high frequencies, the depressed capacitive loop
24 corresponds to the interfacial capacitance with a native oxide layer on the alloy surface [13].

1 At low frequencies, the inductive loop is associated with the relaxation processes related to
2 the weakening of the protective efficiency of the oxides layer due to dissolution [13]. Outliers
3 recorded at very low frequencies can be attributed to the non-stability of the Al corrosion
4 processes. Their elimination was improved from Dygas et al. approach [19].

5 **[Figure 2]**

6
7 The Nyquist diagram of Cu is represented in figure 3. The diagram is characterized by one
8 depressed capacitive loop with the center under the abscissa axis. Because the pH of the test
9 electrolyte induces an active dissolution of Cu, the reaction mechanism proposed for the
10 larger electrode can be interpreted as the charge transfer resistance (R_{ct}) in parallel with the
11 double layer capacity (C_{dl}).

12 **[Figure 3]**

13
14 This approach aims at getting the electrical parameters that are consistent with the materials
15 reactive surface from EIS measurements. Their contributions to the total impedance are well
16 interpreted by analyzing the system thanks to an equivalent circuit.

17 To be useful, the elements of an equivalent circuit should always have a physical meaning in
18 the electrochemical system. In this work, the elements were chosen following these two
19 conditions:

- 20 • numerous electrical models are proposed for Al alloy sample in different medium
21 including numerous associations of resistance, capacitance and inductance [20-23].
22 Because this study is dedicated to compare the electrochemical behaviour of each sample
23 separately with one of both samples coupled electrically during friction, the equivalent
24 electrical circuit has to be chosen both for each material and for the tribosystem
25 constituted by both materials in contact.

1 • Reciprocating test lead to a surface activation that could induce some wrong EIS results,
2 especially for low frequencies, in accord with corrosion phenomena. Thus, to get around
3 this point, one considers only high frequencies.

4 By the way, a simple equivalent circuit of a resistor and a capacitor in parallel is
5 sufficient to extract parameters from diagrams of the impedance, at high frequencies. From
6 Nyquist diagrams, the high frequency domain corresponds to the charges transfer. Indeed, one
7 might suggest that friction will exhibit this phenomenon. So, the inductive behaviour of Al
8 alloy sample has been filtered.

9 Figure 4 exhibits the Nyquist diagram of a Cu disc and an Al pin during friction. It
10 depicts a depressed loop. The raw data and the filtered ones are presented. The filtered data
11 are calculated by filtering raw data with a $R_e(CPE_{hf}, R_{hf})$ circuit. Finally, the filtered data
12 correspond to a weaker frequency range than the raw data, from 10^4 Hz-15.85 mHz to 10^4 Hz-
13 0.5 Hz approximately.

14 **[Figure 4]**

15
16 The selected electrical circuit was a series association $R_e(CPE_{hf}, R_{hf})$ presented in figure 5. R_e
17 is the electrolyte resistance. R_{hf} is a resistance that is associated in parallel with the CPE_{hf} .
18 CPE_{hf} is the Constant Phase Element (hf: high frequencies) used in order to include the
19 divergence from pure capacitive behaviour. The value of CPE_{hf} is as

$$Z_{CPE} = \frac{1}{Q_{hf}(j\omega)^n} \quad (\text{eq. 1})$$

20
21 Q_{hf} is the numerical value of the admittance ($1/|Z_{CPE}|$) at $\omega = 1 \text{ rad.s}^{-1}(\text{S.s}^n.\text{cm}^{-2})$, $j^2 = -1$ the
22 imaginary unit, ω is the angular frequency (rad.s^{-1}) and n is the CPE exponent ($0 \leq n \leq 1$)

23 **[Figure 5]**

1 Then electrical values, resistances and capacitances, calculated from CPE, were compared
2 between Al alloy and Cu samples, between the static contact (Al-Cu) and sliding contact
3 (Al/Cu). These results allow calculating the capacitance according to Brug's relation [24]:

$$4 \quad C_{hf} = Q_{hf} (Q_{hf} R_{hf})^{\frac{1-n}{n}} \quad (\text{eq. 2})$$

5

6 **3.2 Impedance diagrams for Al alloy and Cu, separately**

7 *3.2.1 Al alloy sample*

8 During experiments, the Ecorr changes were lower than 10 mV, which is consistent with the
9 small amplitude of the perturbation voltage for EIS measurements.

10 The values of the electrical components were calculated for the same Al sample and different
11 time of storage in the acid solution, they are shown in Table 2.

12 **[Table 2]**

13 Table 2 exhibits no drastic evolution of the capacitance, the resistance, and n. Thus, it is worth
14 noting that, after 4.5 hours, the electrical behaviour of Al does not suffer changes.

15 *3.2.2 Cu sample*

16 During experiments, the Ecorr of the Cu sample did not suffer significant changes as the Al
17 sample. The capacitance increases according to the exposure time, in acid solution and R_{hf}
18 decreases as summarized in Table 3. The CPE exponent values show that the double layer is
19 less and less homogeneous, probably due to the modification of roughness during dissolution.
20 Moreover, due to the Cu dissolution, sulfate diffusion could occur in order to balance charges.
21 As the potential can be considered as constant, charges number increases according to the
22 exposure time.

23 **[Table 3]**

1 Because pH is 1.7, Cu dissolution can be described following two steps [25]. The first fast
2 step corresponds to the Cu dissolution from $\text{Cu}_{(s)}$ to Cu(I) . $\text{Cu(I)}_{\text{ads}}$ is generally considered as
3 an adsorbed species at the Cu surface and does not diffuse into the bulk solution. The second
4 slower step corresponds to oxidation of Cu(I) in Cu(II) . Consequently, one might suppose that
5 higher value of R_{hf} for Cu than R_{hf} value obtained with Al can be related to a barrier effect of
6 salt of Cu(II) formation decreasing the kinetic rate of Cu dissolution. In addition, the mass
7 transport has a low influence on dissolution of Cu.

8 *3.2.3 Potential at the Potential of Zero Charge (PZC) for Al alloy and Cu*

9 Sliding phenomena partially depend on electrostatic state of material surface in contact. The
10 potential of zero charge (PZC) plays a major role in electrostatic processes. Different PZC
11 values for Cu immersed in different solution are proposed in literature i.e. Bockris and
12 Reddy's report [26]. EIS offers a good method to determine the PZC of materials in solution
13 which is considered like the minimum of the capacitance according to the applied potential
14 [25]. If the capacitance is minimum, the thickness of the double layer is maximum and the
15 charges equilibrium is reached to the zero charge state.

16 A series of impedance spectra for Cu and Al electrodes has been recorded on sulphuric acid
17 solution in a large range of potential (between -0.47 and + 0.37 V vs. E_{corr}). Double layer
18 capacitances evaluated from electrical equivalent circuit described previously, are plotted
19 against applied potential in Figure 6. Capacitances at Open Circuit Potential (OCP) are also
20 reported on the figure 6.

21 **[Figure 6]**

22 Figure 6 shows that C_{hf} of Al sample is approximately constant. The C_{hf} , calculated at open
23 circuit potential (E_{corr}), is four times higher than the one calculated at applied potential.
24 Although the potential value is the same, the previous cathodic polarization modifies the Al

1 alloy surface during applied potential tests. The curve does not exhibit a minimum of
2 capacitance.

3 For the Cu sample, C_{hf} is the lowest at E_{corr} . The minimum corresponding potential is more
4 negative than the E_{corr} . At high frequencies, a capacitive loop from the relaxation of the
5 double-layer capacitance is observed. The faradic process is slow compared to double layer
6 relaxation (phenomena can not be coupled) and specific ions are not adsorbed. However, this
7 last hypothesis could be questioned. Indeed, the capacitance of Cu, at open circuit potential
8 (OCP) potential is not rigorously constant and the salts on the surface could participate in this
9 evolution [25]. The same behaviour could occur at applied potential, close to E_{corr} . However,
10 the evolution of the Cu C_{hf} shows a minimum that is relevant to the PZC value.

11 In this work, the PZC value of Cu sample is estimated to be -0.47 ± 0.04 V versus MSE that is
12 in accordance with Ma *et al.* [25] who found a value of -0.56 V in sulphuric acid, 0.5 mol.L^{-1} .
13 However, experimental protocol does not allow to find the PZC of Al alloy. Thus, one might
14 suggest that the PZC of Al alloy is close to the OCP around -1.13 V vs MSE [26]. Further
15 investigations have to be carried out with only one sample per value of applied potential.
16 Figure 7 shows evolution of OCP of the contact between Al and Cu before, during and after
17 sliding.

18 **[Figure 7]**

19 The OCP value is between one of PZC of Cu and Al. Thus, positive charges on Al alloy
20 surface are opposite to negative ones on Cu surface. If the electrostatic attractions are
21 considered, the friction coefficient would be higher in these conditions meaning that EIS
22 measurements contribute to revealing the synergistic effect in tribocorrosion. However, no
23 friction coefficient can be measured with this equipment. Additional works will be carried out
24 in order to correlate friction coefficient evolution at different applied potential. Related to this

1 electrostatic effect between surfaces in contact, this problem was already highlighted in the
2 case of 316L stainless steel / poly(methyl)methacrylate contact [6].

3
4 **3.3 Impedance diagrams for static and dynamic contacts**

5 **3.3.1 Static contact between Cu and Al**

6 Table 4 shows the capacitance, the resistance and χ^2 , defined as
7 $\chi^2 = \sum_i (\log|Z_{i,experimental}| - \log|Z_{i,calculated}|)^2$, for the static contact between Cu and Al alloy, at high
8 frequencies. The capacitance can be considered constant as well as the resistance.

9 **[Table 4]**

10 Table 5 presents capacitances and resistances of: - Al electrode before contact; -Cu electrode
11 before contact; - Al/Cu static contact: association of Al alloy and Cu in static contact. Table 5
12 presents normalized results (table 5a) and no normalized ones (table 5b) according to areas of
13 each surface.

14 **[Table 5]**

15 On Table 5 a), the capacitance calculated for the static contact was close to the addition of the
16 capacitances of Al alloy and Cu. Moreover, the resistance, R_{hf} , is close to $(1/R_{hf}(Al)) +$
17 $(1/R_{hf}(Cu))$. As a result, the Al alloy and Cu contact is consistent with a parallel association
18 for normalized electrical parameters. On Table 5 b), the results are reported without
19 normalization. The sum of capacitances that are consistent with a parallel association of
20 capacitances is not equal to the capacitance of the static contact. The parallel association of
21 resistances is not consistent with the resistance of the static contact. The no-normalized R_{hf} ,
22 respectively C_{hf} , of the static contact is 20 times lower, respectively 10 times higher, than that
23 of normalized value. Due to the decrease of the R_{hf} , one might suggest that the dissolution is

1 triggered by the galvanic coupling. The potential difference between both materials is
2 significant. Al and Cu samples play roles of the anode and the cathode, respectively.
3 Cathodic reaction (oxygen reduction) occurs on Cu surface and anodic dissolution on Al
4 alloy. The entire Cu surface does not play the role of cathode. Anodic reaction should occur
5 on the Cu worn zone, due to galvanic coupling, during friction. Around the friction zone, one
6 might suggest the local potential should decrease from anodic to cathodic values far from the
7 contact zone.

8 *3.3.2 Dynamic contact made of Cu and Al alloy and post contact*

9 During friction, numerous wear phenomena occur: transfer, oxidation, mechanical
10 degradation as ploughing, wear, etc. The worn area represents 4 % of the entire Cu area. The
11 particular behaviour of the worn track area could not be clearly isolated. As the entire Cu
12 surface was selected, worn track can be neglected for resistance and capacitance
13 consideration. This work could be considered as the first approach.

14 Figures 8 a), b), and c) show the capacitances, the resistances, and the time constants for
15 different experimental durations, respectively. It is worth noting the values are not normalized
16 according to the surface of samples. Five steps have been highlighted on this figure: EIS
17 results for (1) Cu and Al alloy, separately, before friction; (2) static contact, before friction;
18 (3) dynamic contact, friction test; (4) static contact after friction test; (5) separated samples.
19 Each step is discussed below.

20

21 **[Figure 8]**

22

23 *3.3.2.1 Steps 1, 2, and 3*

24 Steps 1 and 2 were analyzed in previous paragraphs. Step 3 indicates that the C_{hf} value
25 decreases when the friction starts. Thus, C_{hf} increases during friction. The R_{hf} increases at the
26 beginning of friction and during friction. The $R_{hf} \cdot C_{hf}$ time constant is the same, at the

1 beginning of friction, as the one at the end of static contact. Thus, during friction, the time
2 constant increases according to the time. At the beginning of friction and during friction, the
3 convection occurs due to Al alloy pin displacement in the solution. The active surface is then
4 disturbed. During the friction, the Cu surface becomes active. After 10 hours of friction, the
5 time constant is higher than that of Al or Cu samples. This increase could be related to the
6 dissolution involved by friction.

7 This electrochemical behaviour is reproducible, two series of experiments were carried out
8 and the same values were obtained.

$$9 \quad \frac{C_{hf}}{S} = \frac{\varepsilon\varepsilon_0}{e} \quad (\text{eq. 3})$$

10 S is the double layer area, e is the thickness, ε and ε_0 are the permittivity of the adsorbed
11 water and of vacuum, respectively.

$$12 \quad R_{hf} \cdot S = \rho \cdot e \quad (\text{eq. 4})$$

13 ρ is the resistivity that varies to the inverse of the ions concentration.

$$14 \quad \text{If } \frac{C_{hf}}{S} \cdot R_{hf} \cdot S = \rho \varepsilon \varepsilon_0 \quad (\text{eq. 5})$$

15 increases, either ρ or ε increases. The friction triggers the dissolution; indeed, the ions
16 concentrations should increase. Thus, the resistivity should decrease contrary to the increase
17 of the product $R_{hf} \cdot C_{hf}$. Therefore, the relative permittivity should increase. The permittivity of
18 the water molecules could account for this evolution. Indeed, according to the orientation of
19 the adsorbed water molecules, the relative permittivity should be changed [28]. Because data
20 seem to prove the increase of ε , the wear mechanisms could modify the charges orientation on
21 materials surface. The EIS results, with taking care attention about the stationary, seem to be
22 consistent with the modification of the double layer. One might suggest that the permittivity is

1 the global physical value that changes. At the ions scale, the corrosion triggers metal ions
2 dissolution. The charge balance involves the anions displacement close to the double layer. In
3 next steps for modelling, the permittivity could be described as a function of ion
4 concentration and/or friction parameters taking into account the permittivity evolution,
5 especially the imaginary part for the dissipative phenomena.

6

7 *3.3.2.2 Step 4*

8 Step 4 concerns the Al-Cu contact after friction. 5 hours after the end of rubbing, the values of
9 the electrical components are close to those of step 3, i.e. during friction. One can conclude
10 that the electrochemical behaviour becomes similar to the one during friction. The dissolution
11 continues being active, because of the enhancement of the galvanic coupling between Cu and
12 Al alloy, after removing the passive layers during friction. Finally, one might suggest that the
13 quality of the rebuilding passive layer is not sufficient for protecting the materials in contact.

14

15 *3.3.2.3 Step 5*

16 Step 5 shows that the resistances of both samples are weaker than those during friction. Thus,
17 the capacitances values increase and the values exhibit discrepancy.

18 The Al resistance, step 5, is approximately equal to Al resistance, step 1. The Cu resistance of
19 step 5 is approximately 100 times lower than that of step 1. The Al and Cu capacitances of
20 step 5 are the same as that of step 1, and 100 times higher than that of step 1, respectively.

21 Finally, one might conclude that the time constant is almost the same for each sample, before
22 contact and after friction. However, The $R_{hf}C_{hf}$ of Al increases according to the time after
23 friction.

1 The decrease of Cu resistance, after friction, could be related to the decrease of the transfer
2 charges resistance on the surface. The increase of the Cu capacitance could be related to the
3 worn zone. The Cu surface increases due to friction zone, in eq. 3. The discrepancy of Cu
4 capacitances (resistances and time constants) values is higher than that of Al sample
5 capacitances. The friction zone on Cu has a significant effect on the electrochemical
6 behaviour. The time constant of Cu sample, after friction, indicates a huge discrepancy.
7 Moreover, due to Al particles, see part 3.4, the galvanic coupling could reinforce the
8 corrosion of Cu. The worn zone is the location of a drastic dissolution; the oxides film is not
9 as efficient as the one outside the worn zone. The contribution of the third body could play a
10 significant role, the interpretation is, nowadays, not obvious. Further investigations will be
11 carried out to better understand the third body contribution.

12

13 ***3.4 Wear track analyses***

14 Figure 9 shows the qualitative EDX analyses and SEM observations of wear track on Cu
15 plate. The gold presence results from sample preparation, after wear tests and before SEM
16 images. The gold deposit was carried out to provide the best images due to presence of
17 insulating oxides on sample surfaces.

18 Figure 9a presents EDX spectrum in the worn zone. It can be compared with figure 9b that
19 represents analyses outside the track. Transferred Al particles are then observed on the Cu
20 sample. Other than the mechanical aspects of wear, previous PZC discussions could partially
21 explain adhesion phenomena of Al on Cu. Figures 9c and 9d exhibit cracks and debris
22 characteristic of fatigue damages.

23 Figure 10 shows qualitative EDX analyses and SEM observations of wear track on Al pin.
24 These pictures highlight numerous Cu deposits on Al alloy confirmed by EDX analyses
25 shown in figure 10a. Figure 10b corresponds to this particle. Figures 10c and 10d respectively

1 show ploughing by Cu on Al and Cu particles, and small debris, agglomerated on the Al alloy
2 sample. Debris particles were probably transferred onto the Al alloy sample by adhesion
3 mechanism.

4

5 **[Figure 9]**

6

7 **[Figure 10]**

8

9 **4. Conclusion**

10 In this present paper, the EIS contribution in tribocorrosion was investigated from a specific
11 friction device on a Cu/Al tribosystem. EIS is well suited for the study of tribocorrosion
12 phenomena because it allows characterization of the physical state of the tribosystem/solution
13 interface.

14 The assumptions are discussed in terms of the frequency range determination to ensure steady
15 state system and to obtain the pertinent interface simulation by an electrical equivalent circuit.
16 Once these key limitations of EIS for tribocorrosion have been solved, this technique is
17 presented as an efficient tool to explain the surface charges contribution to the tribocorrosion
18 wear phenomena.

19 Due to the EIS analyses of each sample, separately, an estimated value of PZC was
20 calculated. According to the E_{corr} during friction, the PZC values predict that the negative
21 charges are on the Cu surface and the positive ones are on the Al surface. Thus adhesion and
22 material transfer could occur, this expectation was confirmed by SEM and EDX analyses.

23 The impedance diagrams of the static contact exhibit that Cu and Al in contact were
24 interpreted by EIS as a parallel association of impedance, with normalized data. The results
25 are consistent with delocalized reactions. About the dynamic contact, EIS informs about an

1 ions concentration decreasing in the double layer. Moreover, the relative permittivity of
2 adsorbed water molecules and ions could account for increasing the time constant.

3 One can conclude that EIS is an interesting tool in order to follow degradations of surfaces
4 submitted to friction. EIS related to tribology could be, in next years, a useful tool for
5 following material behaviour submitted to friction in a solution.

6 Additional works are in progress in order to improve numerous results. The surface ratio on
7 the Cu plate, between a worn surface and an exposed one, will change in order to understand
8 and to follow, by EIS, the location of the cathodic reaction and the reaction rate. Further tests
9 will be carried out with a friction device that will allow monitoring tangential load and the
10 dissipated energy for relating the mechanical parameters to the electrochemistry. Moreover,
11 EIS could be an interesting method to complete previous investigations, such as fretting-
12 corrosion tests.

13

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Tables

Table 1: A 2017 chemical composition (weight %).

Table 2: EIS results calculated from Al sample immersed in acid solution.

Table 3: EIS results calculated from Cu sample immersed in acid solution.

Table 4: EIS results calculated from static contact between Cu and Al.

Table 5: EIS results from: -Al electrode; Cu electrode; Al-Cu static contact ; a) results are reported according to an area normalization of samples, Al area of 0.28 cm², Cu area of 19.64 cm²; b) results are reported without normalization.

Table 1: A 2017 chemical composition (weight %).

Elements	Cu	Mn	Mg	Si	Fe	Zn	Cr	Pb	Ti	Sn	Ni	Al
Weight %	4.00	0.71	0.66	0.66	0.44	0.17	< 0.05	< 0.05	0.03	< 0.02	< 0.01	bal

Table 2: EIS results calculated from Al sample immersed in acid solution.

Duration hour	C_{hf} μF	Err (C_{hf}) μF	n	Err (n)	R_{hf} ohm	Err (R_{hf}) ohm	χ^2
1.5	12.8	4.8	0.88	0.05	6110	1360	$1.0 \cdot 10^{-3}$
3	12.6	4.2	0.89	0.07	5950	1165	$1.7 \cdot 10^{-3}$
4.5	12.8	4	0.90	0.07	5575	1315	$1.6 \cdot 10^{-3}$

Table 3: EIS results calculated from Cu sample immersed in acid solution.

Duration hour	C_{hf} μF	Err (C_{hf}) μF	n	Err (n)	R_{hf} ohm	Err (R_{hf}) ohm	χ^2
3	98	4	0.85	0.04	1590	42	$4.2 \cdot 10^{-3}$
5	118	4	0.84	0.12	997	25	$3.8 \cdot 10^{-3}$
6	171	8	0.81	0.01	615	15	$4.6 \cdot 10^{-3}$
6.5	192	8	0.81	0.01	549	13	$4.2 \cdot 10^{-3}$
7.5	200	8	0.81	0.01	519	13	$4.0 \cdot 10^{-3}$

Table 4: EIS results calculated from static contact between Cu and Al.

Duration hour	C_{hf} μF	Err (C_{hf}) μF	R_{hf} ohm	Err (R_{hf}) ohm	χ^2
23	1577	122	52	1	$2.0 \cdot 10^{-3}$
25	1573	110	50	1	$1.7 \cdot 10^{-3}$
27	1656	20	52	1	$1.6 \cdot 10^{-3}$
29	1658	20	53	2	$1.7 \cdot 10^{-3}$
31	2060	169	45	1	$2.2 \cdot 10^{-3}$

Table 5: EIS results from: -Al electrode; Cu electrode; Al-Cu static contact ;

a) results are reported according to an area normalization of samples, Al area of 0.28 cm^2 , Cu area of 19.64 cm^2 .

b) results are reported without normalization

a)	C_{hf} $\mu F \cdot \text{cm}^{-2}$	Err (C_{hf}) $\mu F \cdot \text{cm}^{-2}$	R_{hf} ohm.cm ²	Err (R_{hf}) ohm.cm ²
Al	64	22	1176	256
Cu	8	1	$16.78 \cdot 10^3$	$0.43 \cdot 10^3$
Al-Cu static contact	87	5	989	26
$C_{hf}(\text{Al}) + C_{hf}(\text{Cu})$	72	23		
$(1/R_{hf}(\text{Al}) + 1/R_{hf}(\text{Cu}))^{-1}$			1099	141
b)	C_{hf} μF	Err (C_{hf}) μF	R_{hf} ohm	Err (R_{hf}) ohm
Al	13	4	5878	1280
Cu	156	6	854	22
Al-Cu static contact	1705	88	50	1
$C_{hf}(\text{Al}) + C_{hf}(\text{Cu})$	169	7		
$(1/R_{hf}(\text{Al}) + 1/R_{hf}(\text{Cu}))^{-1}$			746	22

Figure captions

Fig. 1: a) Experimental device of tribocorrosion; b) Al pin, design and insulating.

Fig. 2: Al EIS diagrams, Nyquist plot representation, raw impedance data, after immersion in Na_2SO_4 (0.5 mol.L^{-1}) buffered to pH 1.7 by H_2SO_4 for 3 hours.

Fig. 3: Cu EIS diagrams, Nyquist plot representation, raw impedance data, after immersion in Na_2SO_4 (0.5 mol.L^{-1}) buffered to pH 1.7 by H_2SO_4 for 5 hours.

Fig. 4: Al & Cu EIS diagrams, raw impedance data, after 45 hours of immersion

Fig. 5: Equivalent electrical circuit for high frequencies; R_e : electrolyte resistance; CPE_{hf} : constant phase element, R_{hf} : transfer resistance.

Fig. 6: Capacitances evolution for Al and Cu electrodes, according to applied potential; Mercurous Sulphate Electrode (MSE); Open Circuit Potential (OCP).

Fig. 7: E_{corr} during friction between Al pin and Cu plate; solution: Na_2SO_4 0.5 mol.L^{-1} and sulphuric acid, pH = 1.7.

Fig. 8: a) Capacitances (C_{hf}) log scale, b) resistances (R_{hf}) log scale and c) time constants ($C_{\text{hf}}.R_{\text{hf}}$) linear scale during 5 steps: (1)-before contact, Al and Cu separately, (2)-static contact between Al and Cu, (3)-dynamic contact between Al and Cu, (4)-static contact between Al and Cu after friction, (5)- after friction and separated samples of Al and Cu.

Fig. 9: a) EDX spectrum of Cu sample on the center of the worn zone, after step 5; b) EDX spectrum of Cu sample on the outer worn zone; c) SEM image on the center of the worn zone, Cu sample; d) SEM observation.

Fig. 10: a) EDX spectrum of Cu transferred on Al electrode, after step 5; b) EDX spectrum of Al sample on a worn zone; c) SEM image of Al sample, deposit of Cu on Al; d) SEM image of Al sample on the center of the worn zone.

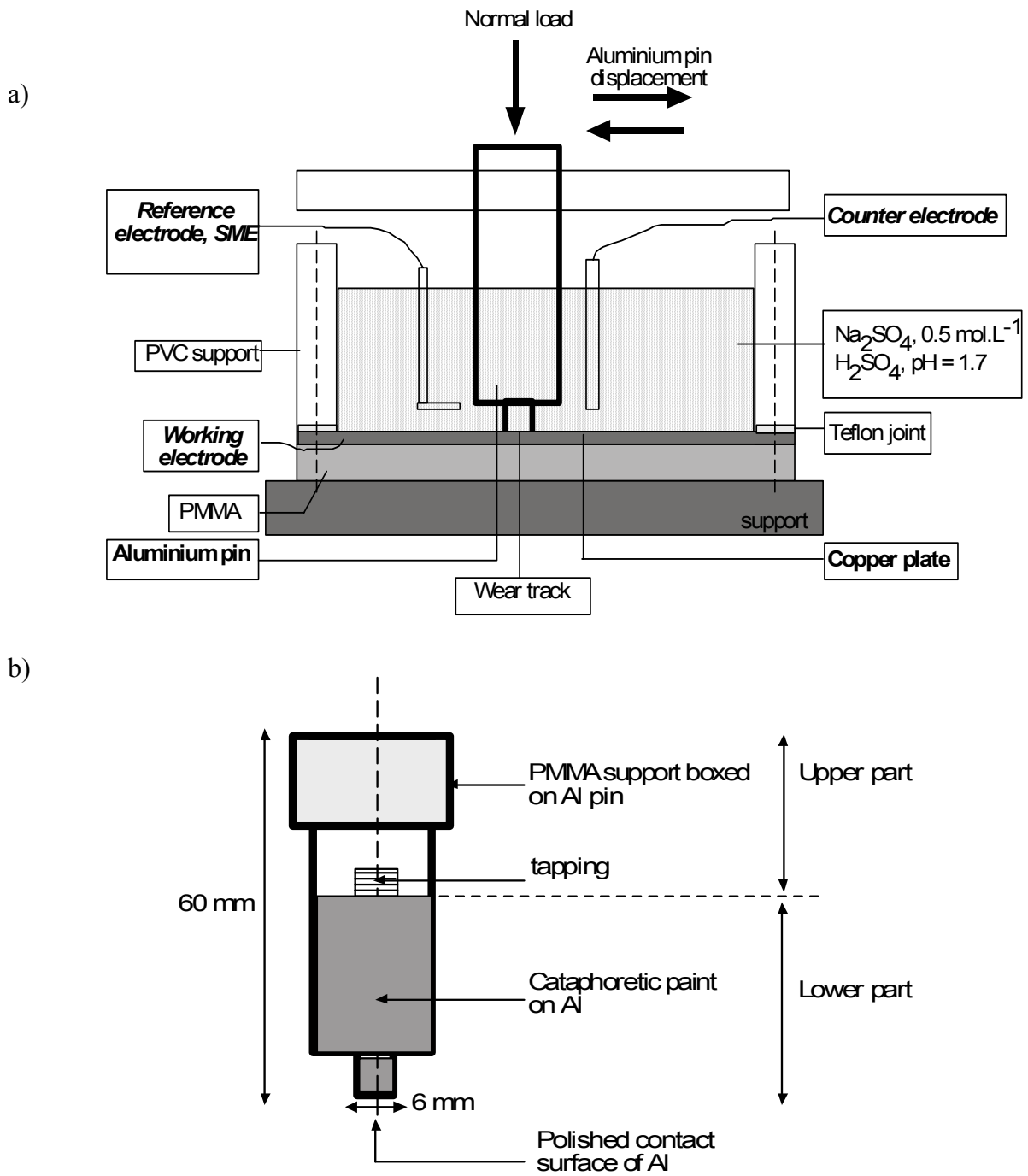


Fig. 1

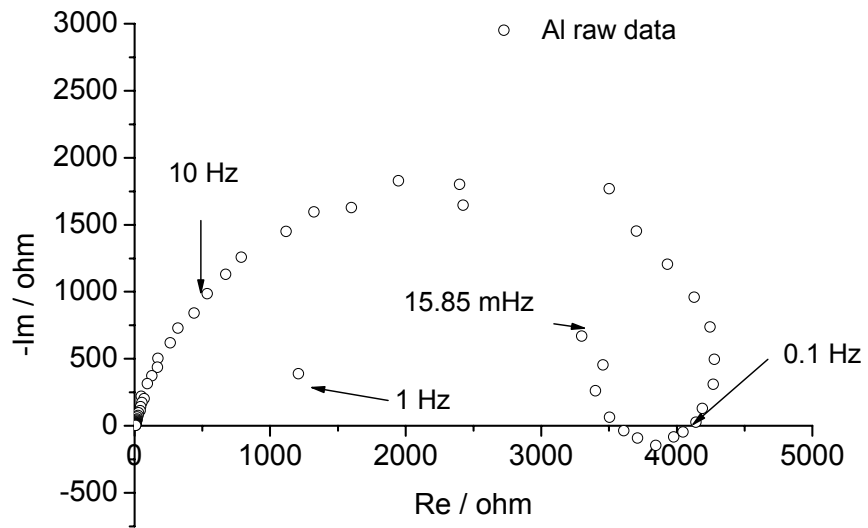


Fig. 2

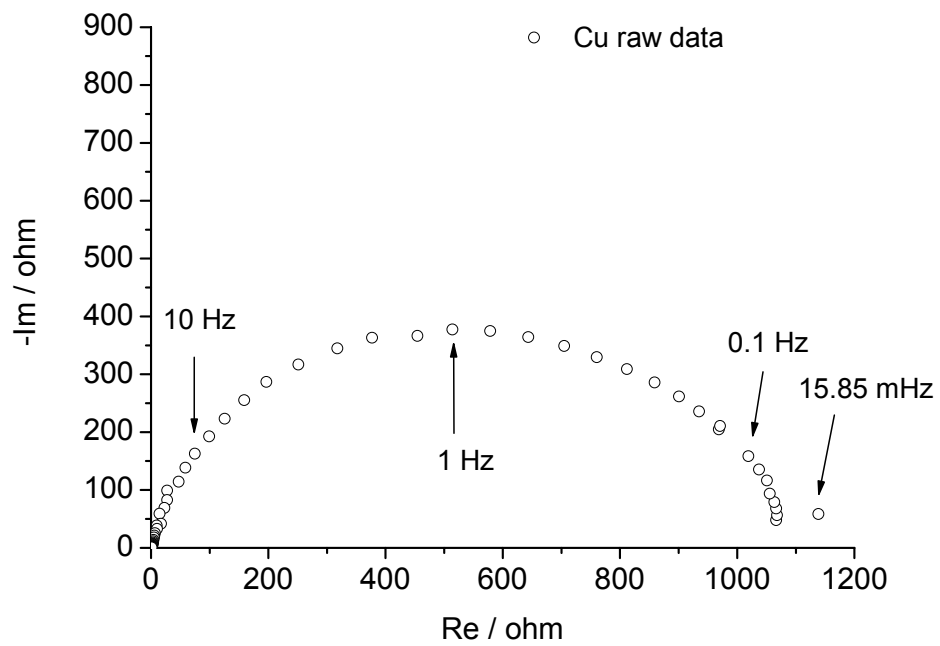


Fig. 3

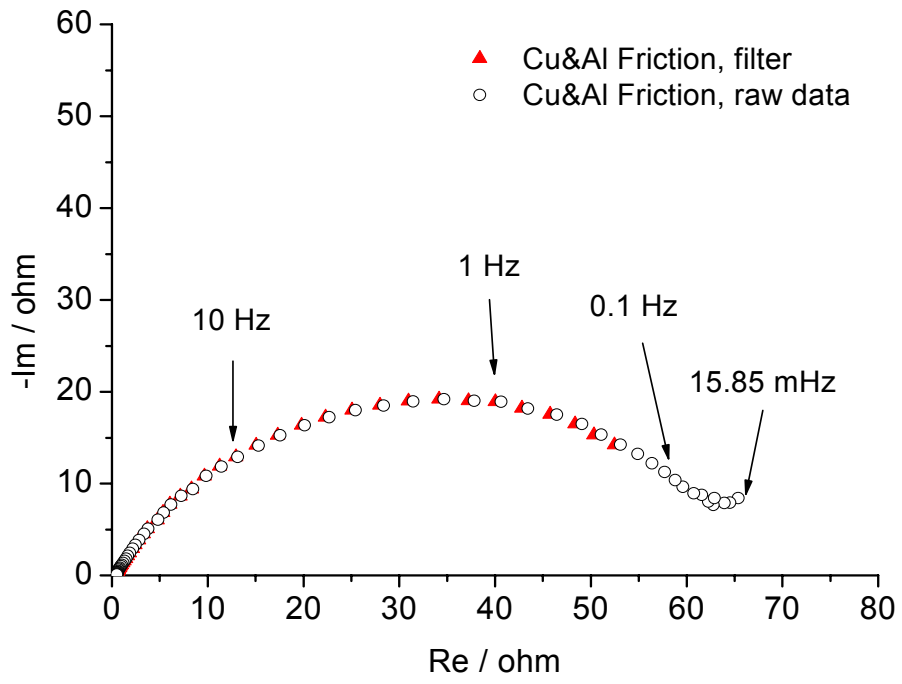


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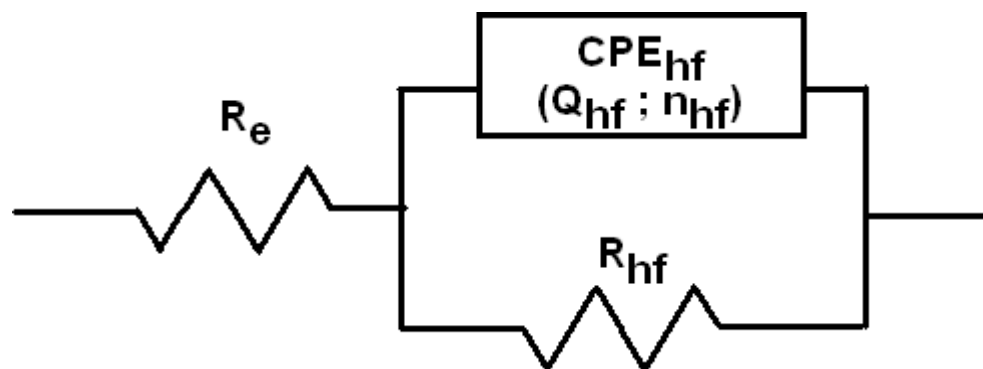


Fig. 5

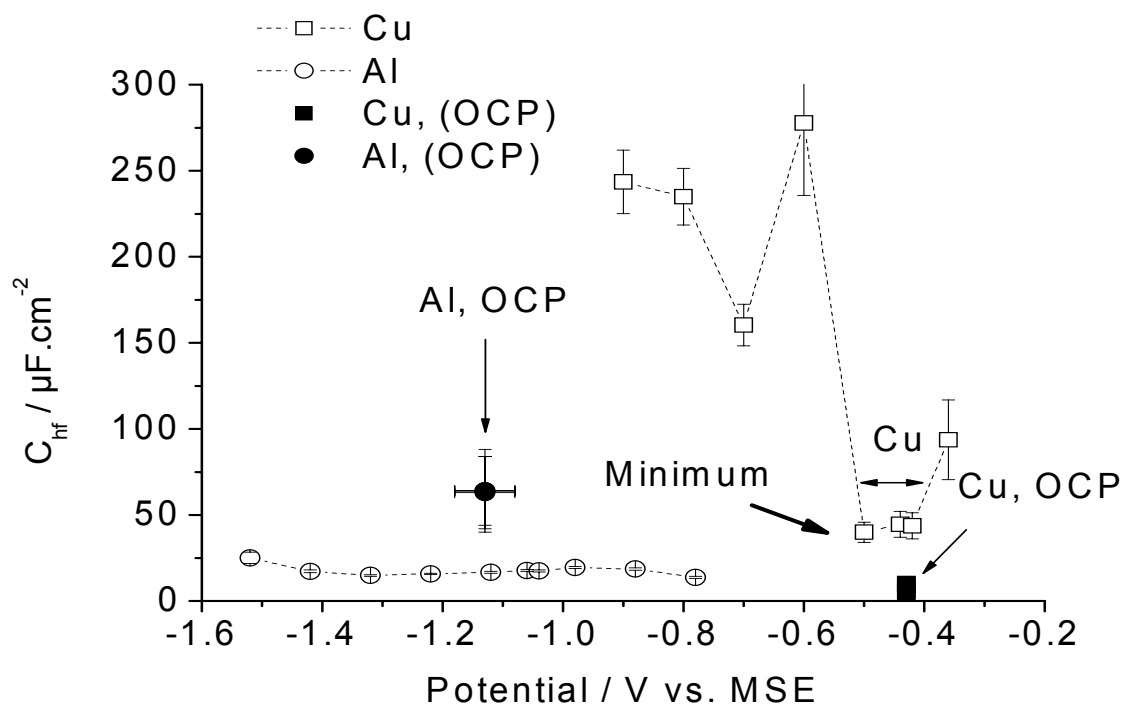


Fig. 6

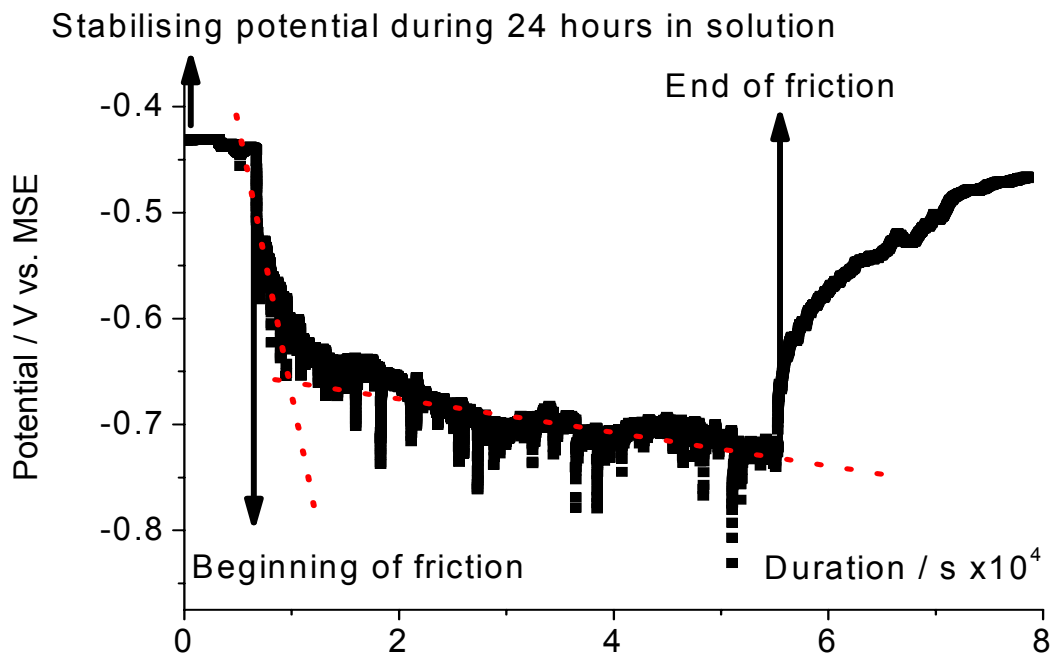
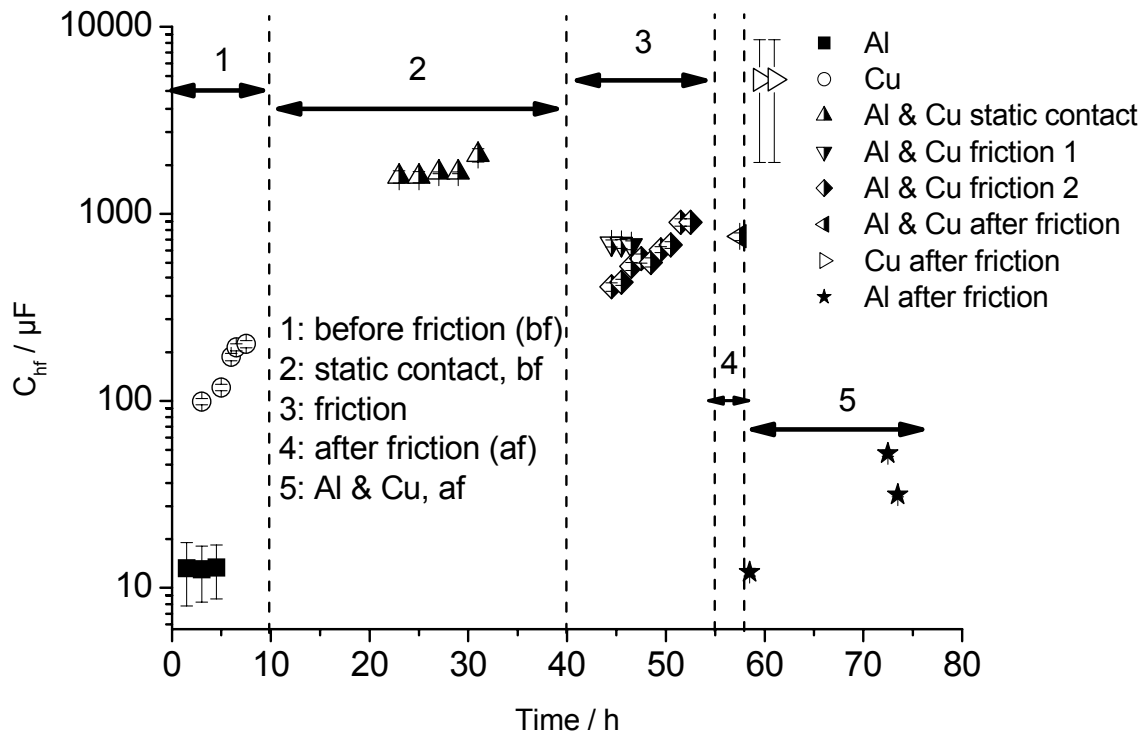


Fig. 7

a)



b)

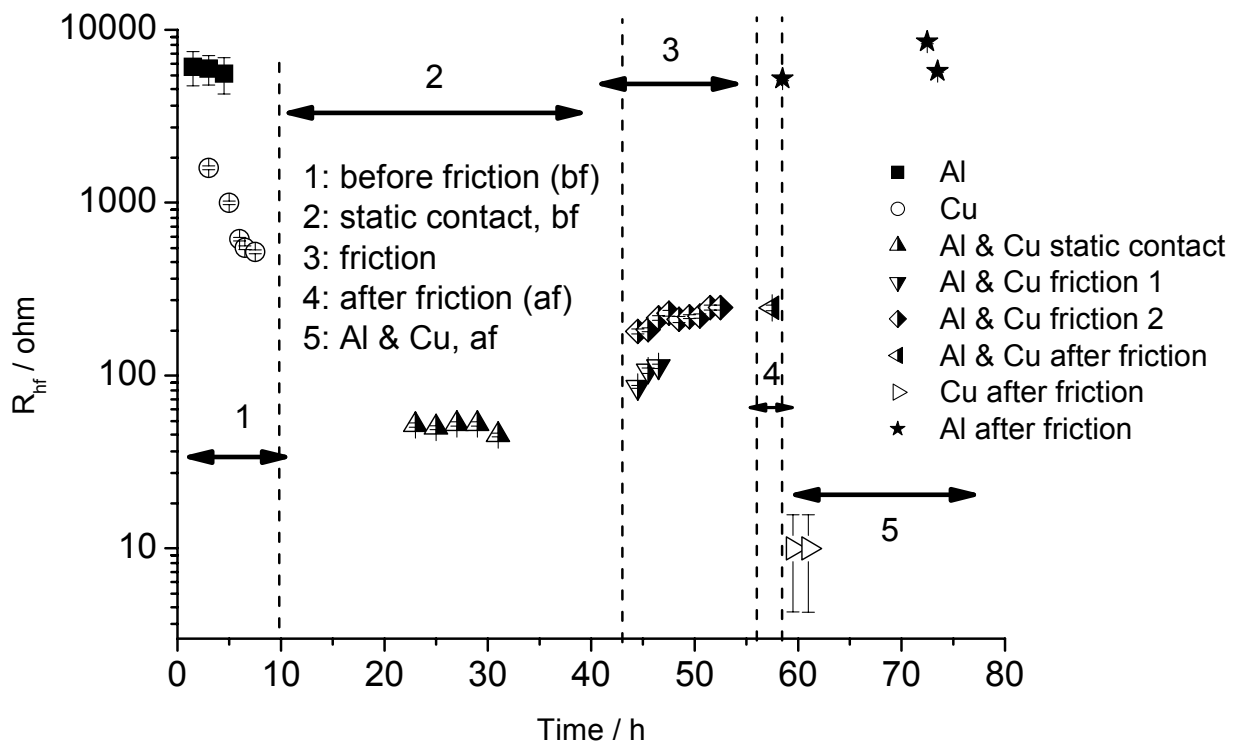


Fig. 8a & 8b

c)

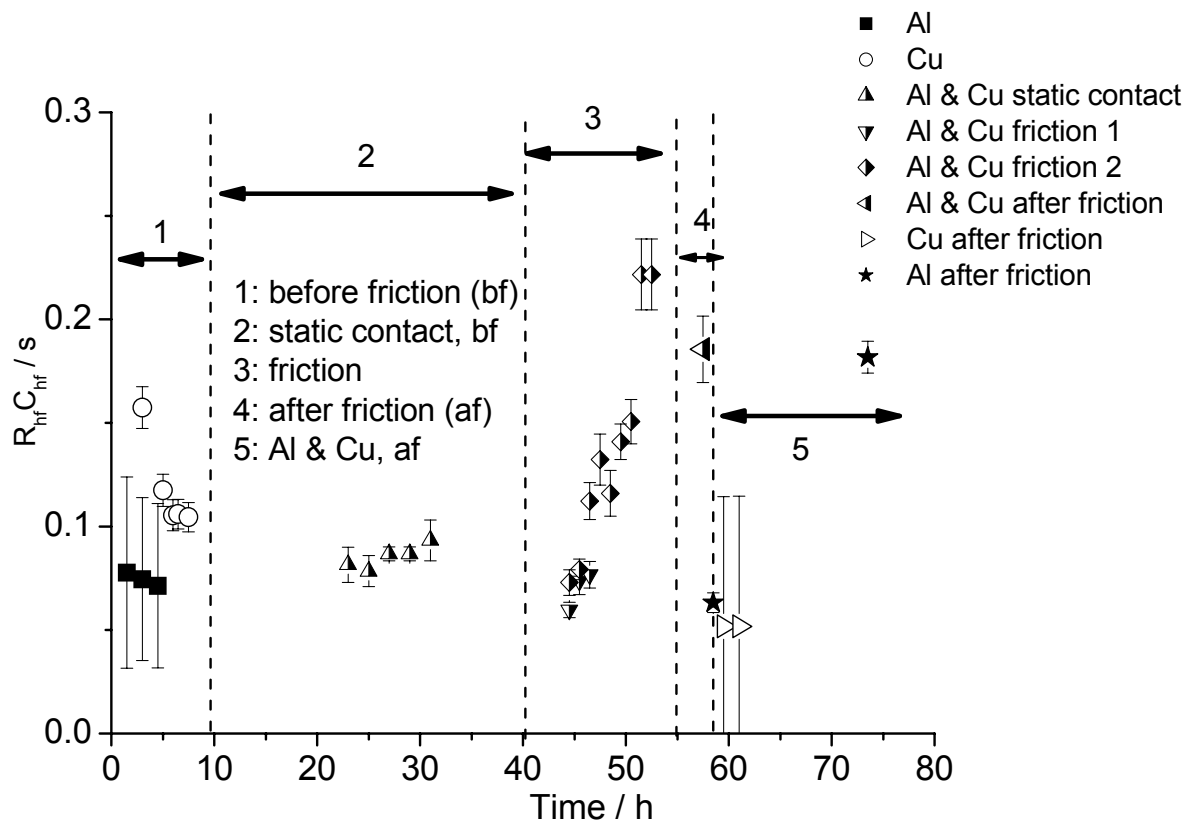


Fig. 8c

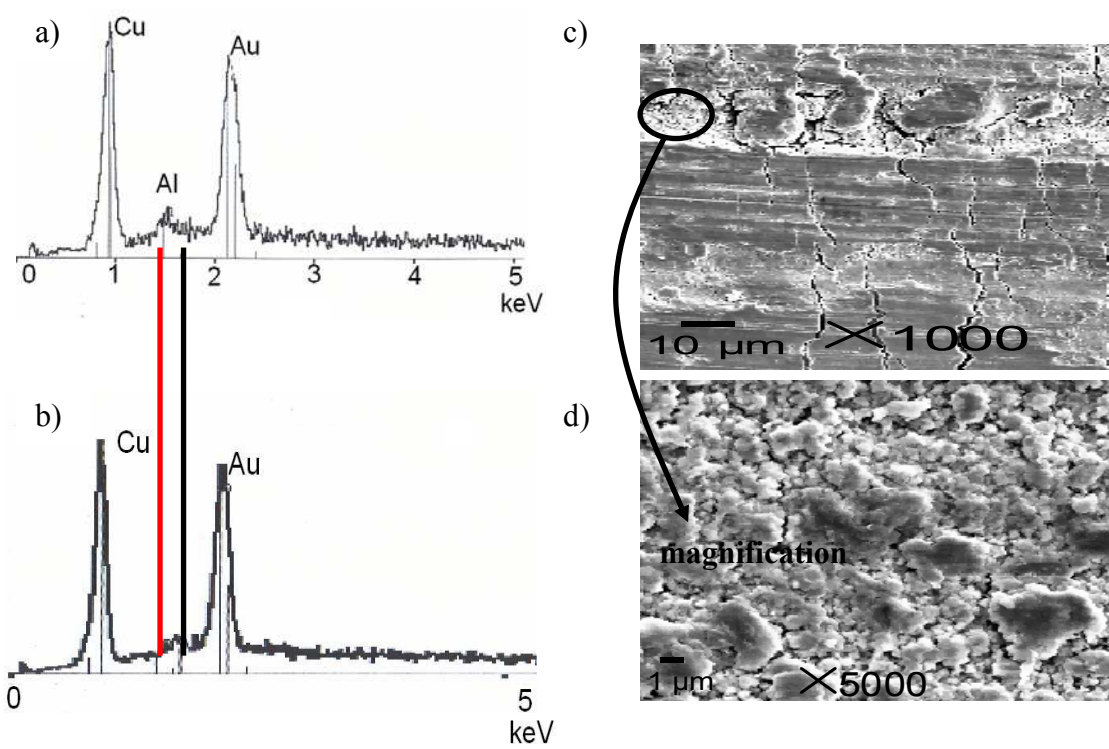


Fig. 9

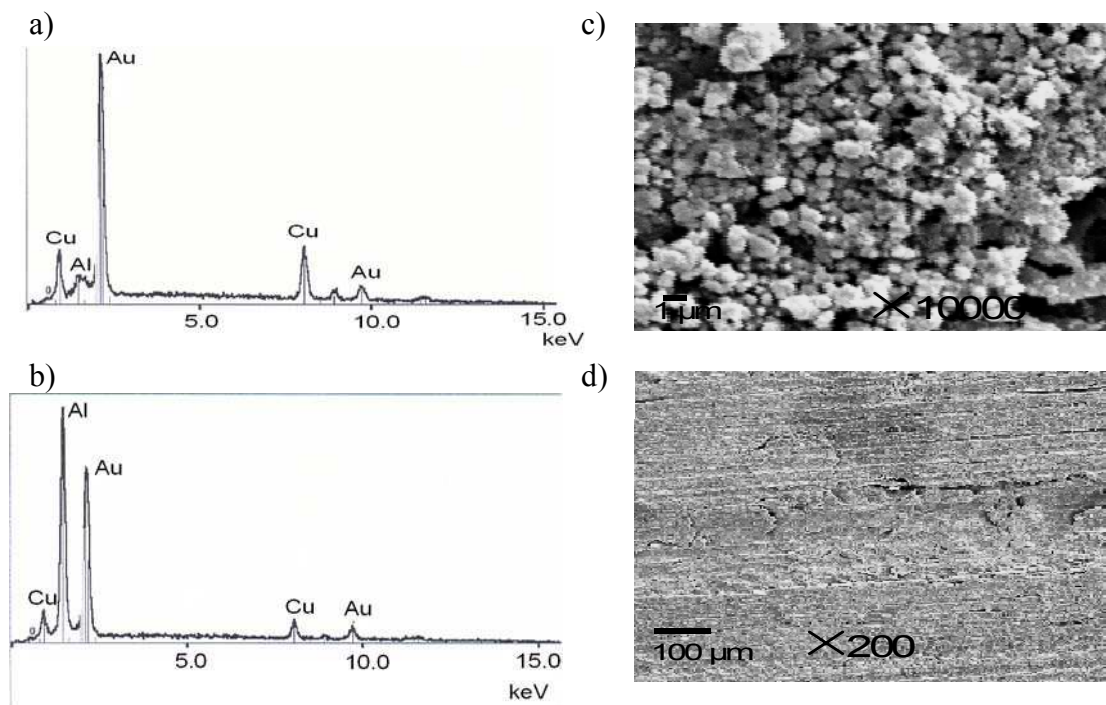


Fig. 10